

Shisheng Xiong

List of Publications by Year in descending order

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33
papers

886
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567281

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times ranked

1296
citing authors

| # | ARTICLE | IF | CITATIONS |
|----|---|------|-----------|
| 1 | Co decoration of molybdenum sulfide and carbon for improving lithium ion capacity of large monolayer MXene cathodes. <i>Journal of Alloys and Compounds</i> , 2022, 902, 163702. | 5.5 | 2 |
| 2 | Fabrication of Nanodevices Through Block Copolymer Self-Assembly. <i>Frontiers in Nanotechnology</i> , 2022, 4, . | 4.8 | 15 |
| 3 | Dewettingâ€Assisted Patterning of Organic Semiconductors for Microâ€OLED Arrays with a Pixel Size of 1Åµm. <i>Small Methods</i> , 2022, 6, e2101509. | 8.6 | 12 |
| 4 | Roadmap on emerging hardware and technology for machine learning. <i>Nanotechnology</i> , 2021, 32, 012002. | 2.6 | 104 |
| 5 | CO ₂ -Based Dual-Tone Resists for Electron Beam Lithography. <i>Advanced Functional Materials</i> , 2021, 31, 2007417. | 14.9 | 20 |
| 6 | Electron Beam Lithography: CO ₂ -Based Dual-Tone Resists for Electron Beam Lithography (Adv. Funct. Mater. 13/2021). <i>Advanced Functional Materials</i> , 2021, 31, 2170086. | 14.9 | 1 |
| 7 | Highly Luminescent and Patternable Block Copolymer Templated 3D Perovskite Films. <i>Advanced Materials Technologies</i> , 2021, 6, 2001209. | 5.8 | 10 |
| 8 | Self-Aligned Assembly of a Poly(2-vinylpyridine)-b-Polystyrene-b-Poly(2-vinylpyridine) Triblock Copolymer on Graphene Nanoribbons. <i>ACS Applied Materials & Interfaces</i> , 2021, 13, 41190-41199. | 8.0 | 0 |
| 9 | MonkeyPosekit: Automated Markerless 2D Pose Estimation of Monkey. , 2021, , . | | 0 |
| 10 | Nanotube network arrays with nickel oxide canopies as flexible high-energy anodes for lithium storage. <i>Journal of Alloys and Compounds</i> , 2020, 847, 156366. | 5.5 | 4 |
| 11 | Boundary-directed epitaxy of block copolymers. <i>Nature Communications</i> , 2020, 11, 4151. | 12.8 | 22 |
| 12 | Three-Dimensional PrGO-Based Sandwich Composites With MoS ₂ Flowers as Stuffings for Superior Lithium Storage. <i>Frontiers in Chemistry</i> , 2020, 8, 94. | 3.6 | 1 |
| 13 | Directed self-assembly of block copolymers for sub-10 nm fabrication. <i>International Journal of Extreme Manufacturing</i> , 2020, 2, 032006. | 12.7 | 35 |
| 14 | Combining double patterning with self-assembled block copolymer lamellae to fabricate 10.5 nm full-pitch line/space patterns. <i>Nanotechnology</i> , 2019, 30, 455302. | 2.6 | 8 |
| 15 | Enhanced microphase separation of thin films of low molecular weight block copolymer by the addition of an ionic liquid. <i>Soft Matter</i> , 2019, 15, 9991-9996. | 2.7 | 2 |
| 16 | Pathways to Mesoporous Resin/Carbon Thin Films with Alternating Gyroid Morphology. <i>ACS Nano</i> , 2018, 12, 347-358. | 14.6 | 35 |
| 17 | Sub-10 nm silicon FinFET devices on SOI substrate made by block copolymer lithography. , 2018, , . | | 1 |
| 18 | The Solvent Distribution Effect on the Self-Assembly of Symmetric Triblock Copolymers during Solvent Vapor Annealing. <i>Macromolecules</i> , 2018, 51, 7145-7151. | 4.8 | 20 |

| # | ARTICLE | IF | CITATIONS |
|----|--|------|-----------|
| 19 | Directed Self-Assembly of Polystyrene- <i>b</i> -poly(propylene carbonate) on Chemical Patterns via Thermal Annealing for Next Generation Lithography. <i>Nano Letters</i> , 2017, 17, 1233-1239. | 9.1 | 97 |
| 20 | Sub-10-nm patterning via directed self-assembly of block copolymer films with a vapour-phase deposited topcoat. <i>Nature Nanotechnology</i> , 2017, 12, 575-581. | 31.5 | 155 |
| 21 | Quantitative Three-Dimensional Characterization of Block Copolymer Directed Self-Assembly on Combined Chemical and Topographical Prepatterned Templates. <i>ACS Nano</i> , 2017, 11, 1307-1319. | 14.6 | 43 |
| 22 | The One-Pot Directed Assembly of Cylinder-Forming Block Copolymer on Adjacent Chemical Patterns for Bimodal Patterning. <i>Macromolecular Rapid Communications</i> , 2017, 38, 1700285. | 3.9 | 9 |
| 23 | Directed self-assembly of high- χ block copolymer for nano fabrication of bit patterned media via solvent annealing. <i>Nanotechnology</i> , 2016, 27, 415601. | 2.6 | 19 |
| 24 | Directed Self-Assembly of Triblock Copolymer on Chemical Patterns for Sub-10-nm Nanofabrication via Solvent Annealing. <i>ACS Nano</i> , 2016, 10, 7855-7865. | 14.6 | 62 |
| 25 | Directed self-assembly of block copolymer films on atomically-thin graphene chemical patterns. <i>Scientific Reports</i> , 2016, 6, 31407. | 3.3 | 20 |
| 26 | Evolutionary Optimization of Directed Self-Assembly of Triblock Copolymers on Chemically Patterned Substrates. <i>ACS Macro Letters</i> , 2014, 3, 747-752. | 4.8 | 64 |
| 27 | InAs Nanowires Grown by Metal-Organic Vapor-Phase Epitaxy (MOVPE) Employing PS/PMMA Diblock Copolymer Nanopatterning. <i>Nano Letters</i> , 2013, 13, 5979-5984. | 9.1 | 15 |
| 28 | Revealing the Interfacial Self-Assembly Pathway of Large-Scale, Highly-Ordered, Nanoparticle/Polymer Monolayer Arrays at an Air/Water Interface. <i>Nano Letters</i> , 2013, 13, 1041-1046. | 9.1 | 22 |
| 29 | Transformation of a Close-Packed Au Nanoparticle/Polymer Monolayer into a Large Area Array of Oriented Au Nanowires via E-beam Promoted Uniaxial Deformation and Room Temperature Sintering. <i>Journal of the American Chemical Society</i> , 2011, 133, 11410-11413. | 13.7 | 10 |
| 30 | Integration of a Close-Packed Quantum Dot Monolayer with a Photonic Crystal Cavity Via Interfacial Self-Assembly and Transfer. <i>Small</i> , 2010, 6, 2126-2129. | 10.0 | 13 |
| 31 | Free-Standing, Patternable Nanoparticle/Polymer Monolayer Arrays Formed by Evaporation Induced Self-Assembly at a Fluid Interface. <i>Journal of the American Chemical Society</i> , 2008, 130, 3284-3285. | 13.7 | 61 |
| 32 | Removing twin images in X-ray fluorescence holography. <i>Optics Communications</i> , 2004, 229, 123-129. | 2.1 | 2 |
| 33 | A method of improving spatial resolution in X-ray fluorescence holography. <i>Optik</i> , 2003, 114, 317-321. | 2.9 | 2 |